



PATENT
2185-0475P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: TANIMURA et al. Conf.: 8209
Appl. No.: 09/689,592 Group: 1713
Filed: October 13, 2000 Examiner: M. L. REDDICK
For: PROCESS FOR PRODUCING POLYOLEFIN-BASED
RESIN COMPOSITION (AS AMENDED)

#10/B
Jude
4/1/03

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REPLY UNDER 37 C.F.R. § 1.111

Assistant Commissioner for Patents
Washington, DC 20231

March 25, 2003

Sir:

In reply to the Examiner's Office Action dated March 25, 2003, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

IN THE SPECIFICATION:

Please replace the paragraph beginning on page 2, line 14, with the following rewritten paragraph:

--However, although the dispersability of the polymer fine particles as the anti-blocking agent in the polyolefin-based resin was fairly improved compared to that of an inorganic antiblocking agent such as silica fine particles, to that of the polymer fine particles as the anti-blocking agent in the polyolefin-based resin is not necessarily sufficient, and the polyolefin-based composition

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